

Topological heterostructures of layered telluride compounds

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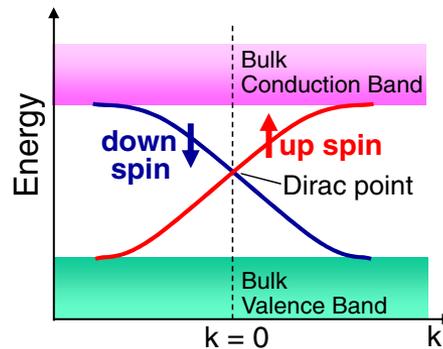
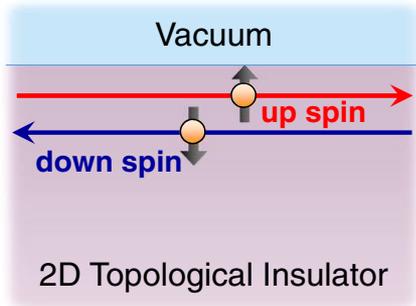
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Topological insulator (TI)

New matter arisen from topological insulating nature

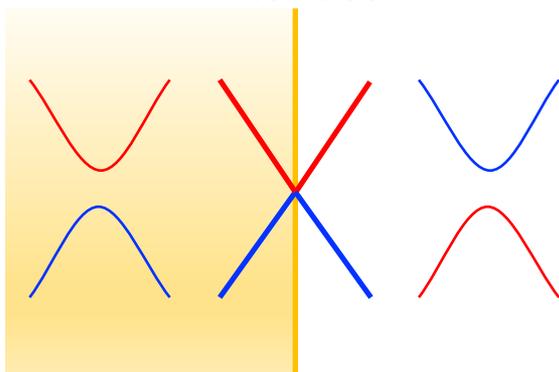


Topological insulator materials

CdTe/HgTe/CdTe (2D), $\text{Bi}_{1-x}\text{Sb}_x$, Bi_2Se_3 , Bi_2Te_3 , Sb_2Te_3 , $\text{Ge}_1\text{Bi}_{4-x}\text{Sb}_x\text{Te}_7$, $\text{Bi}_2\text{Te}_2\text{Se}$, TlBiSe_2 , SnTe etc.

Y. Ando, *J. Phys. Soc. Jpn.* **82** (2013) 102001

Topological insulator Interface Vacuum



Strong spin-orbit coupling



Band inversion in bulk



The band must cross at the interface resulting in the formation of Dirac cone.

Features

- Dirac cone at the surface
- Helical spin states

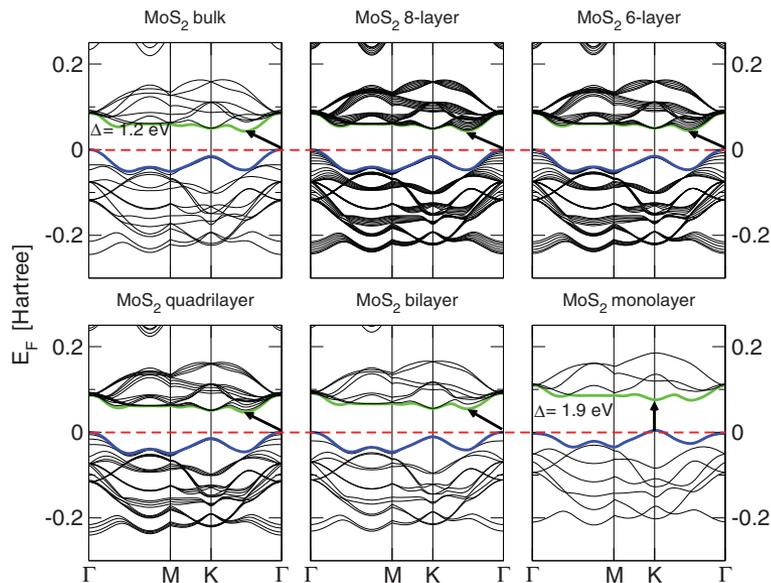
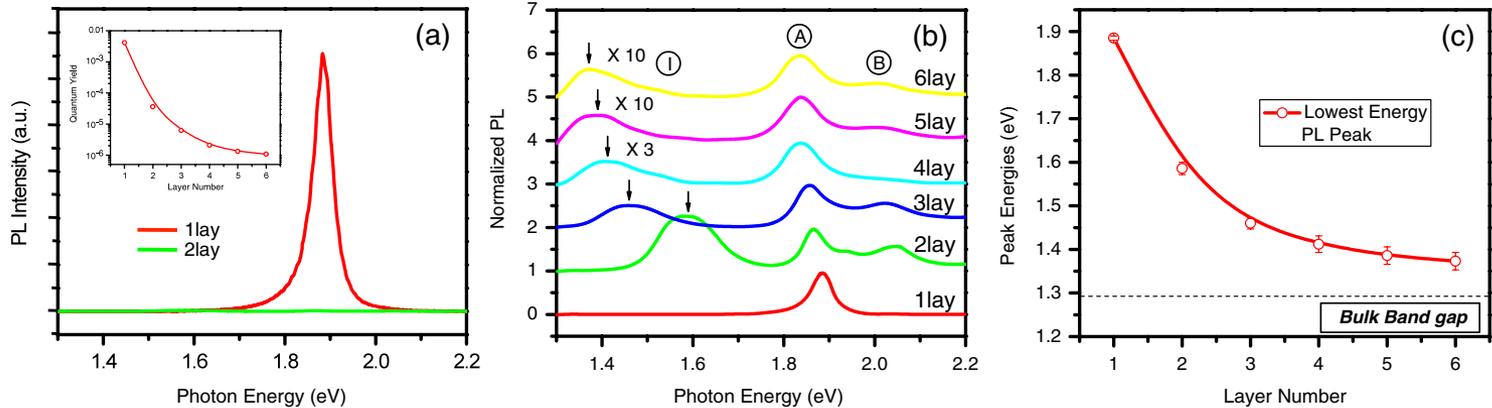


Applications

- THz detector
- Non-dissipative device
- Spintronics

Transition metal dichalcogenide (TMD)

MoS₂, MoSe₂, MoTe₂, WS₂, WSe₂, WTe₂,... (MX₂)



K. F. Mak et. al., Phys. Rev. Lett. 105, 136805 (2010)

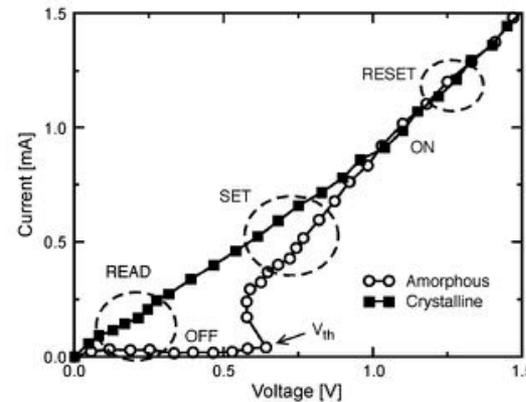
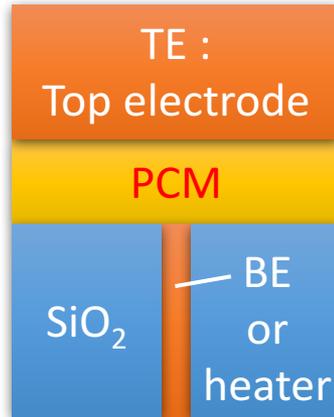
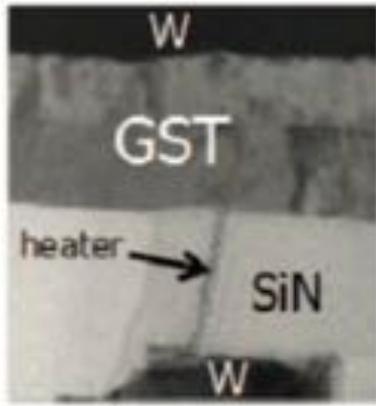
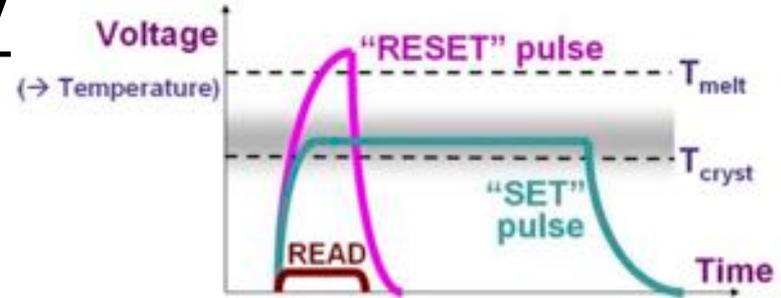
A. Kuc et. al., Phys. Rev. B, 83, 245213 (2011)

Phase change memory

PCM (Phase Change Material)

Chalcogenides

Ge-Sb-Te alloy ($\text{GeTe-Sb}_2\text{Te}_3$)



H.-S. P. Wong et al., *Proceedings of IEEE*, **98**, 2201 (2010)
 G. W. Burr et al., *IEEE J. Emerg. Selected Topics in Circuit and Systems*, **6**, 146 (2016)

3D XPOINT™ TECHNOLOGY

Technology	Latency	Size of Data
SRAM	1X	1X
DRAM	~10X	~100X
3D XPoint™	~100X	~1,000X
NAND	~100,000X	~1,000X
HDD	~10 MillionX	~10,000 X

Technology claims are based on comparisons of latency, density and write cycling metrics amongst memory technologies recorded on published specifications of available memory products against internal Intel specifications.

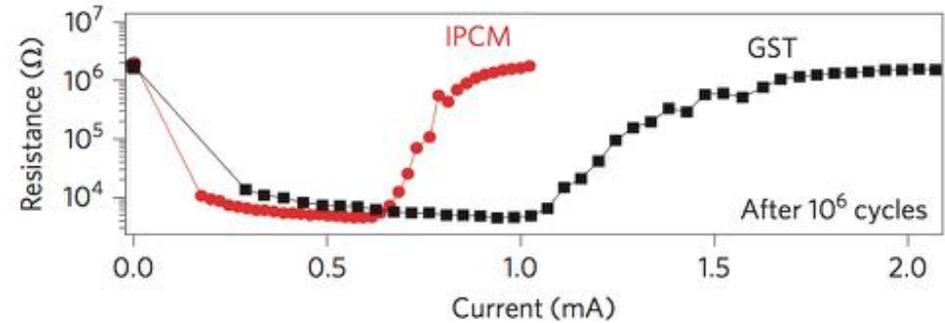
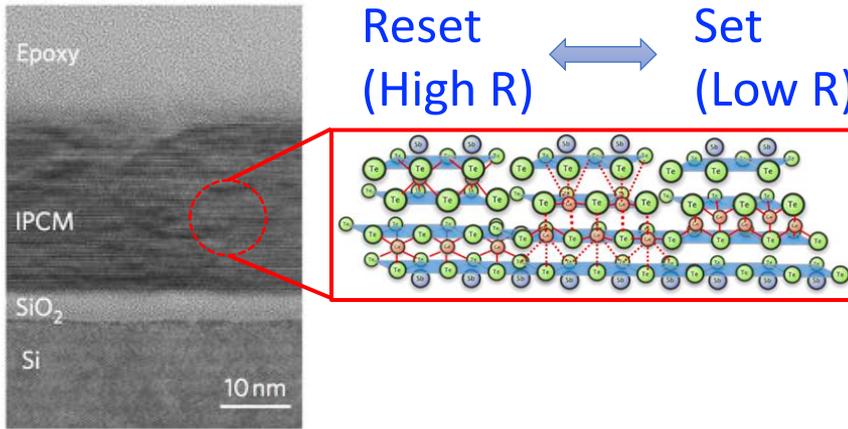
XPoint: Memory/OTS Elements

- Top & bottom cell stacked
- TWL/TE/PCM/ME/OTS/BE/BL2/BL1/TE/PCM/ME/OTS/BE/BWL
- PCM: $\text{Ge}_{0.12}\text{Sb}_{0.25}\text{Te}_{0.64}(\text{Si}_{0.09})$, OTS: $\text{Se}_{0.44}\text{As}_{0.25}\text{Ge}_{0.1}\text{S}_{0.17}$

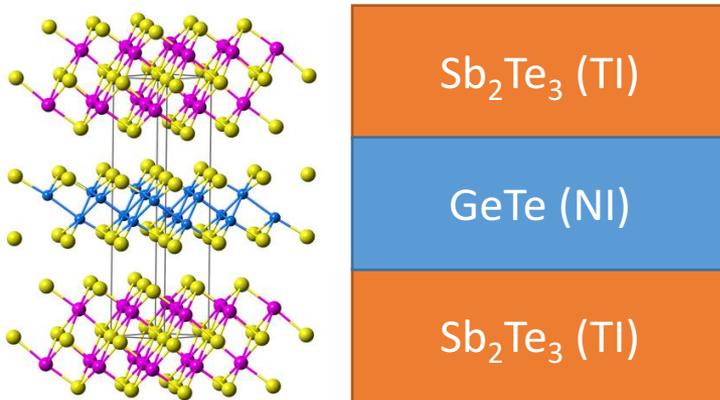
Flash Memory Summit 2017, Santa Clara, CA

Chalcogenide superlattices for phase change memory

GeTe/Sb₂Te₃ superlattice



- A. V. Kolobov et al., *Nat. Mater.* **3**, 703 (2004)
- J. Tominaga et al., *Jap. J. Appl. Phys.* **47**, 5463 (2008)
- R. E. Simpson et al., *Nat. Nanotech.* **6**, 501 (2011)



➔ **NI/TI stacking**
 TI : Topological insulator
 NI : Normal insulator

Unusual electronic properties are expected.

Motivation

- Exploration of electronic structures of chalcogenide heterostructures.

MoTe₂/Sb₂Te₃ (TMDC/TI)

GeTe/Sb₂Te₃ (NI/TI, phase change memory)

Methods

- Density functional theory code: WIEN2k*
- Functional: GGA-PBE or mBJ-LDA**
- Spin orbit coupling (soc)
- Geometry relaxation: DFT-D3 (Grimme)***

* K. Schwarz and P. Blaha. Comp. Mater. Sci. 28, 259 (2003).

** F. Tran and P. Blaha. Phys. Rev. Lett. 102, 226401 (2009).

*** S. Grimme. J. Comput. Chem. 25, 1463 (2004).

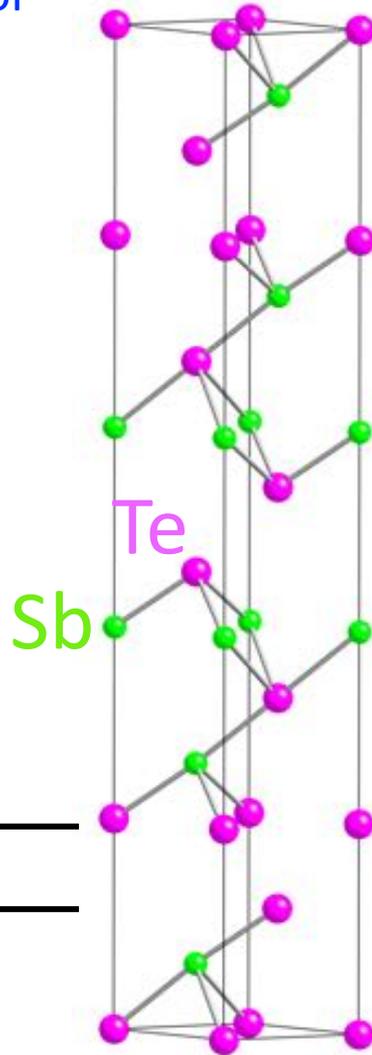
Band structure of Sb_2Te_3

Typical topological insulator

Bulk Sb_2Te_3

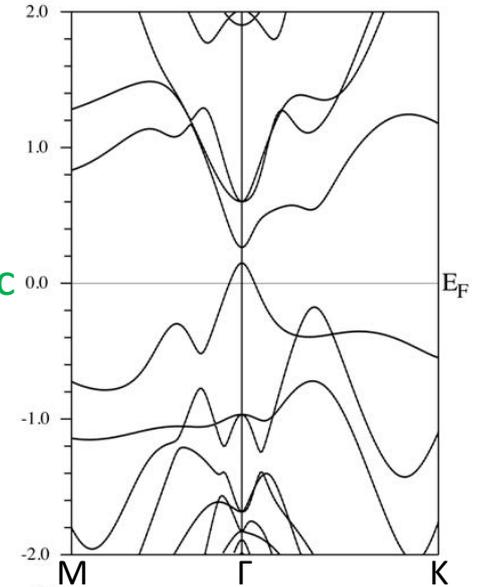
Space group : 166 (R-3m)
 $a = 4.262 \text{ \AA}$, $c = 30.435 \text{ \AA}$

W.-S. Kim, *J. Alloys and Comp.*,
252, 166 (1997)

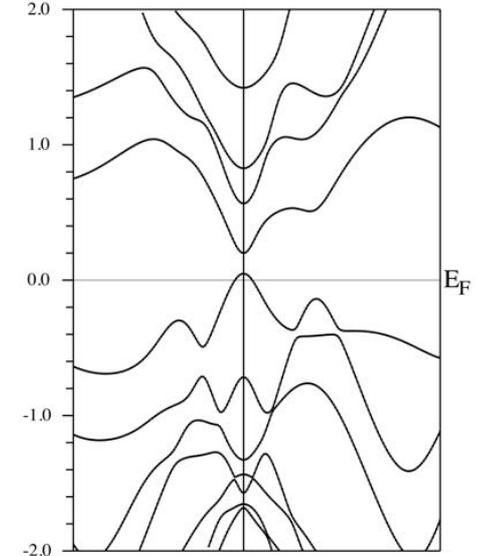


Van der Waals gap

without soc

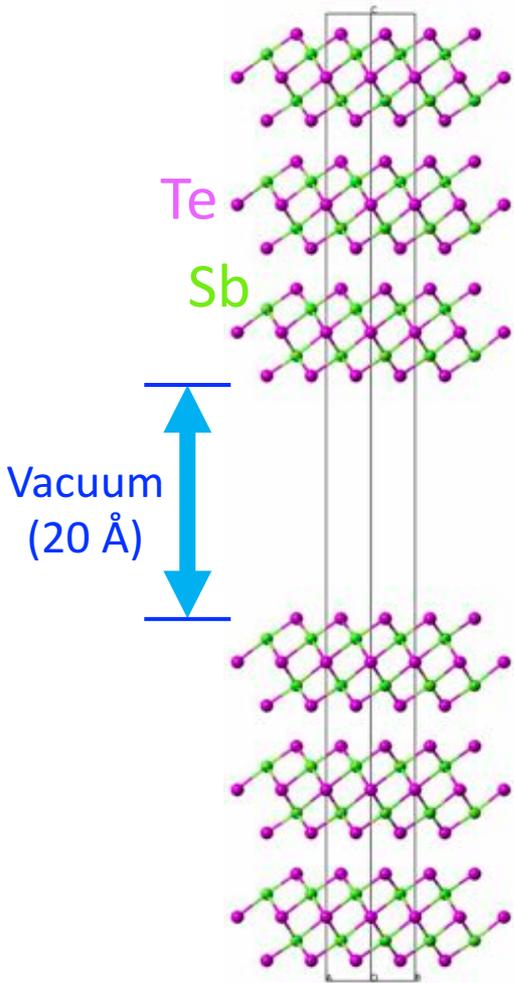


with soc



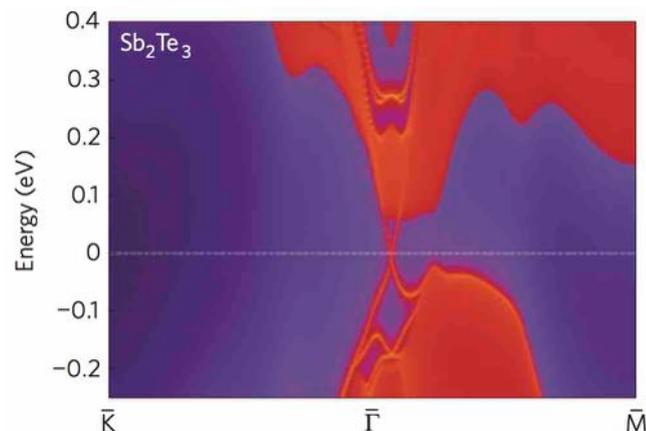
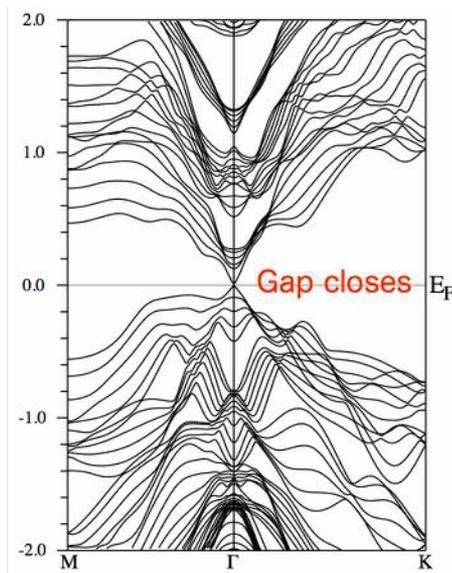
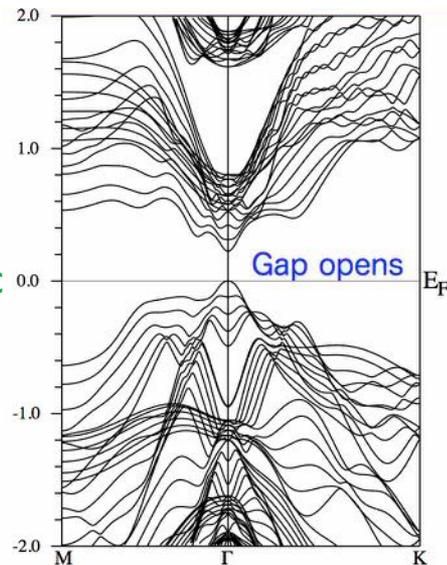
Band structure including vacuum slab

Sb_2Te_3 -6QL-vacuum (20Å)
(QL: Quintuple layer)

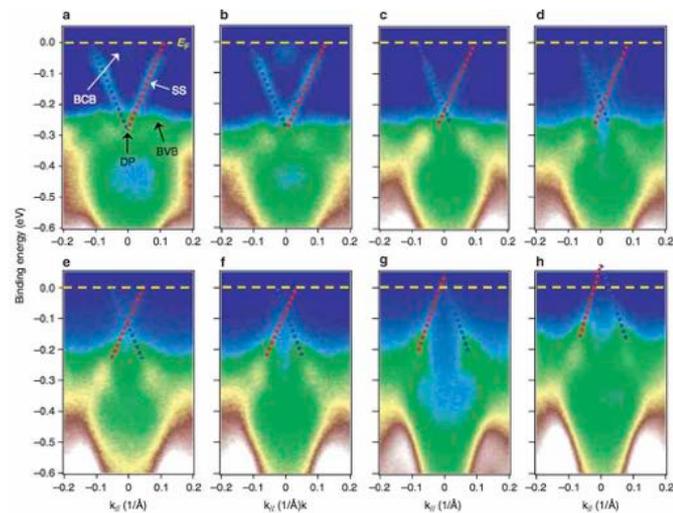


without soc

with soc



H. Zhang et al., *Nat. Phys.*, **5**, 438 (2009)

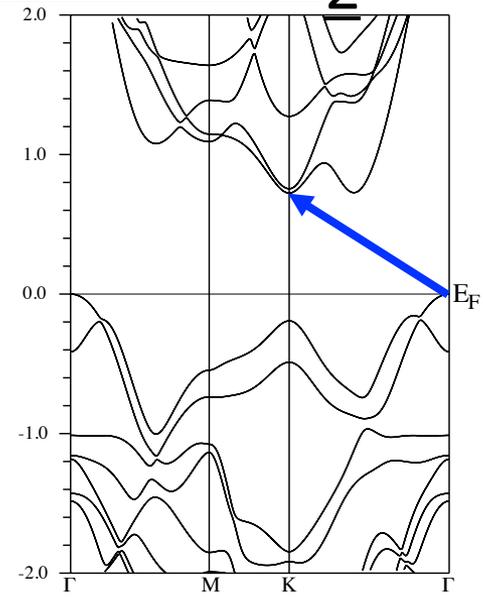
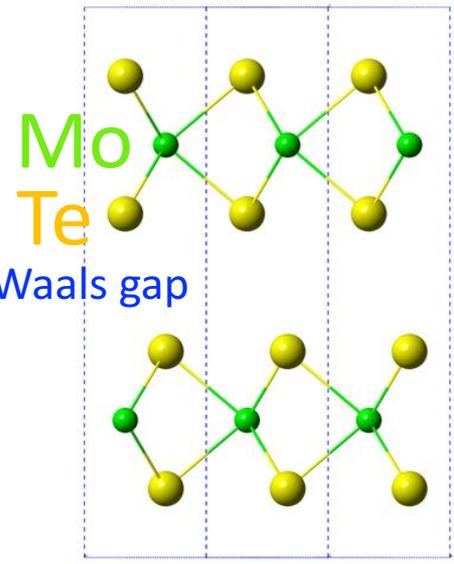


J. Zhang et al., *Nat. Comm.*, **2**, 574 (2011)

Dirac cone at the Γ point

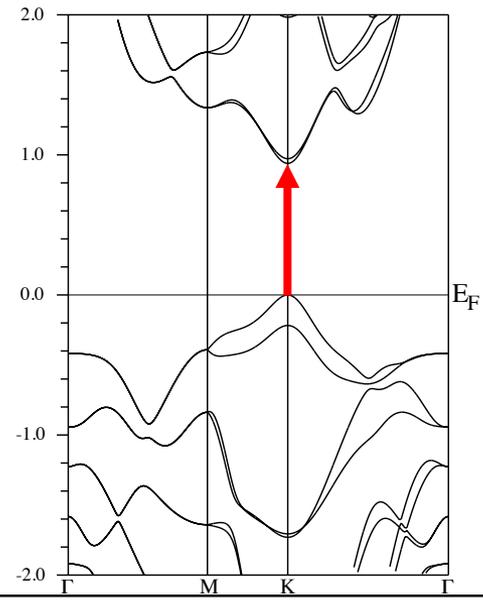
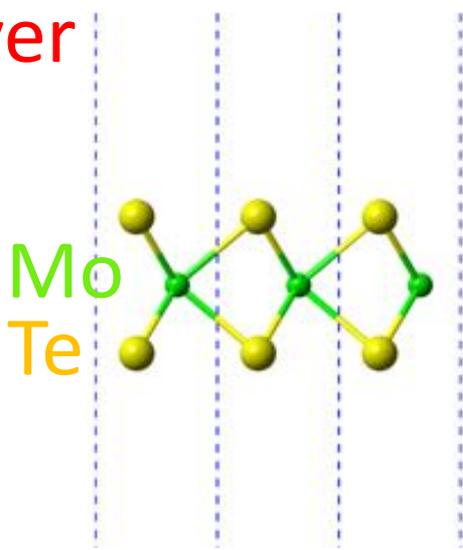
Band structures of MoTe₂

Bulk



Indirect transition

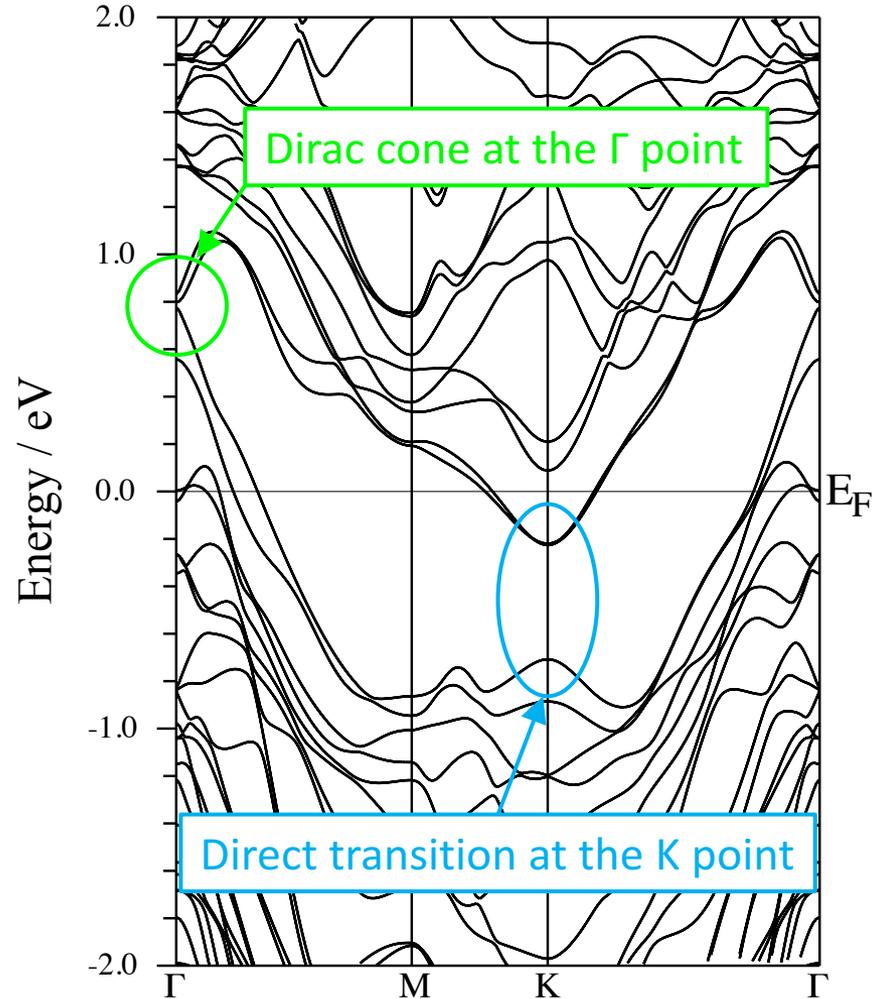
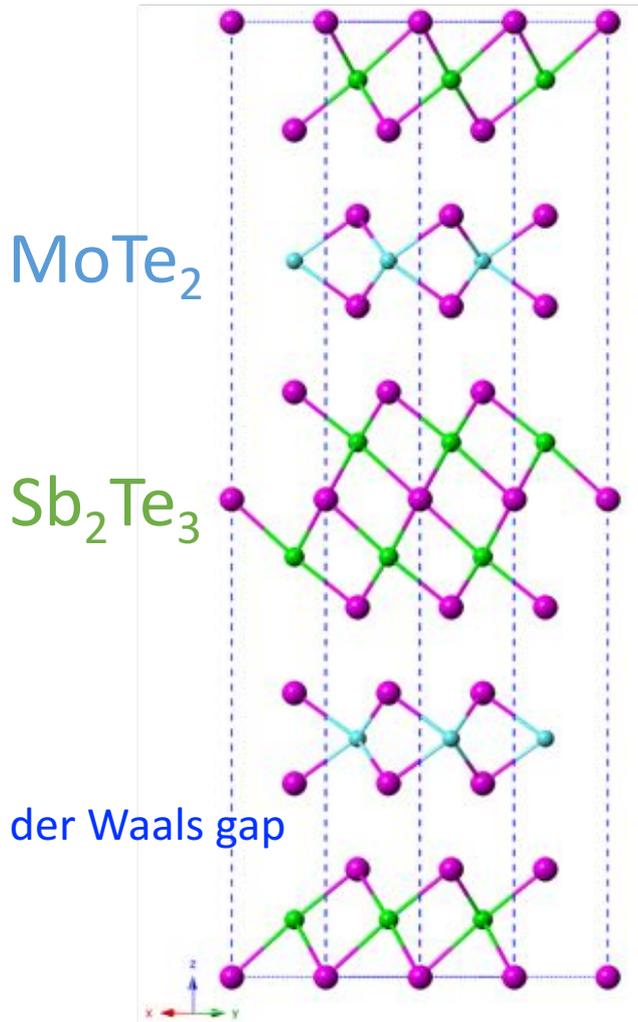
Monolayer



Direct transition

Transition at the K point

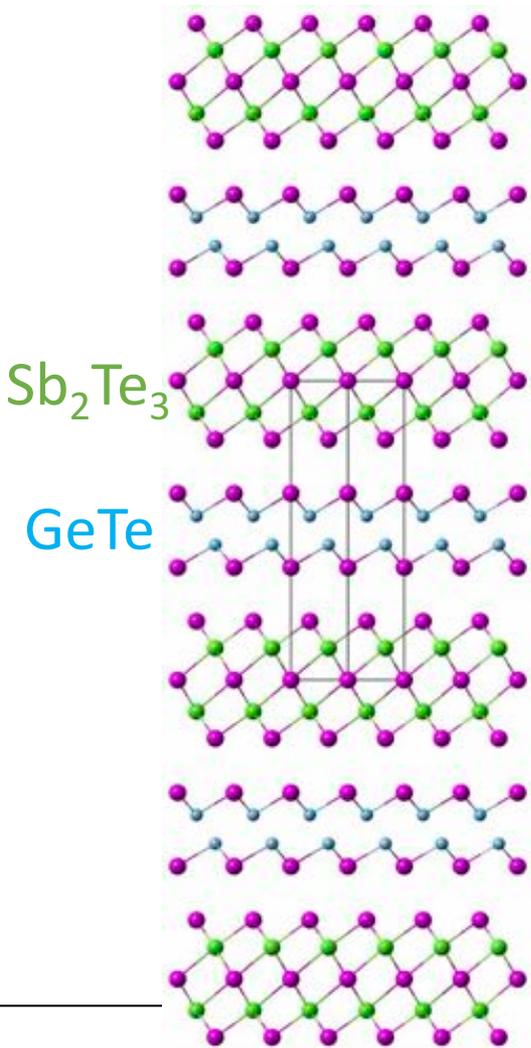
MoTe₂/Sb₂Te₃ heterostructure



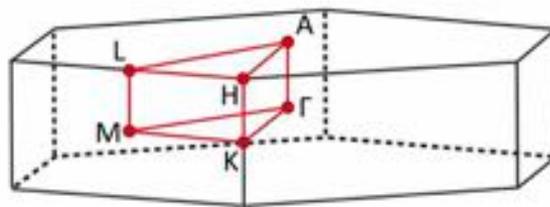
GeTe/Sb₂Te₃ heterostructure

GeTe : Normal insulator, Sb₂Te₃ : topological insulator

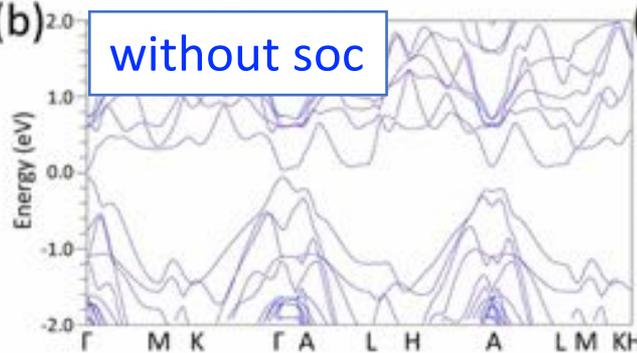
(GeTe)₂/(Sb₂Te₃)₁ superlattice



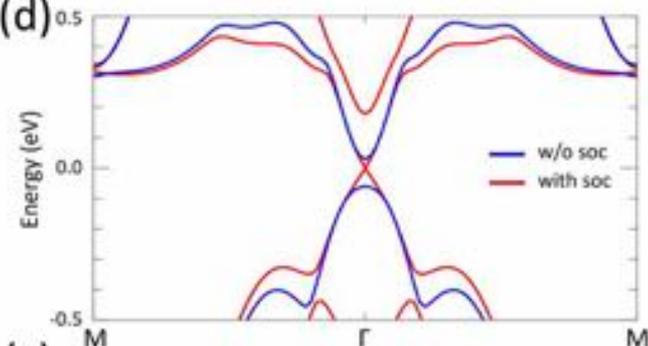
(a)



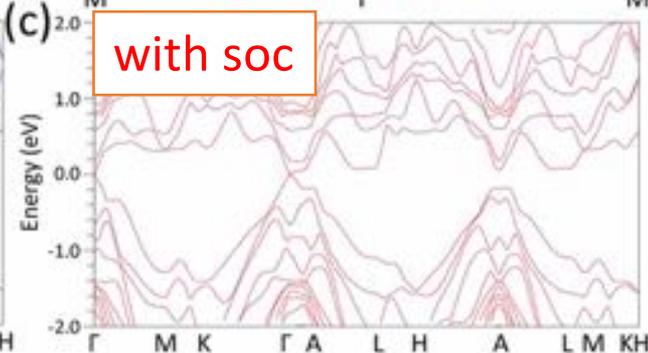
(b)



(d)



(c)



Y. Saito et al., *ACS Appl. Mater. Interfaces*, **9**, 23918 (2017)

Band gap tuning

Tensile



Stress



Compressive

-1.0 GPa

-0.7 GPa

-0.45 GPa

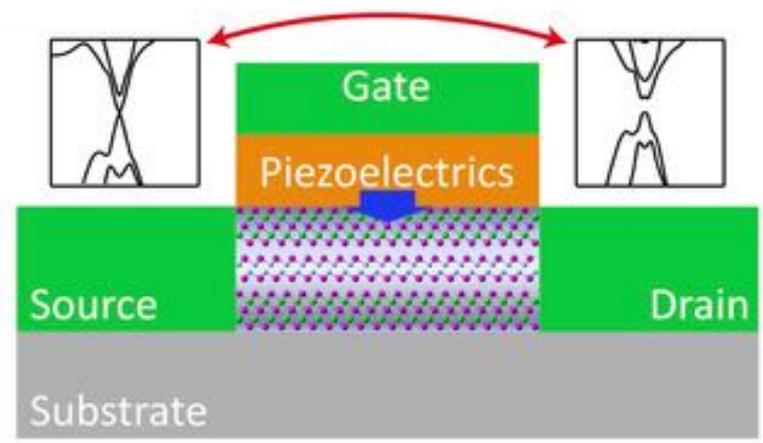
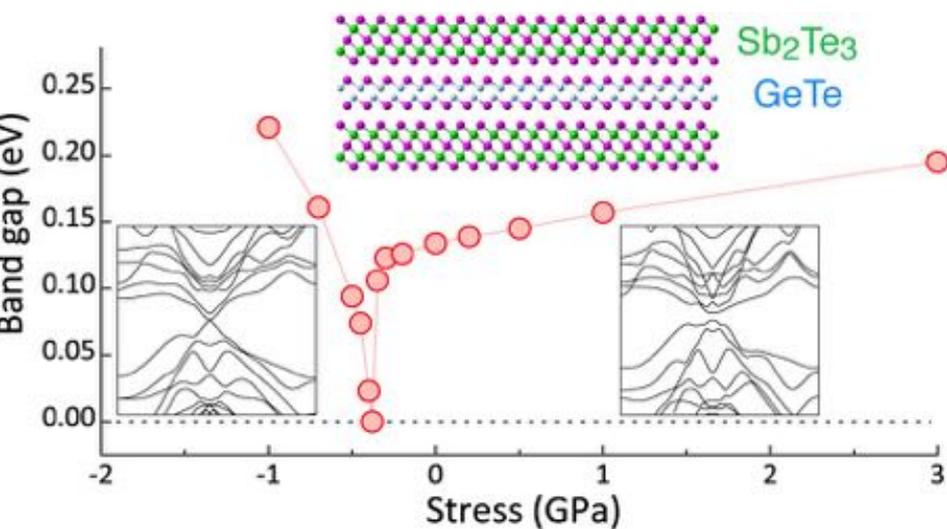
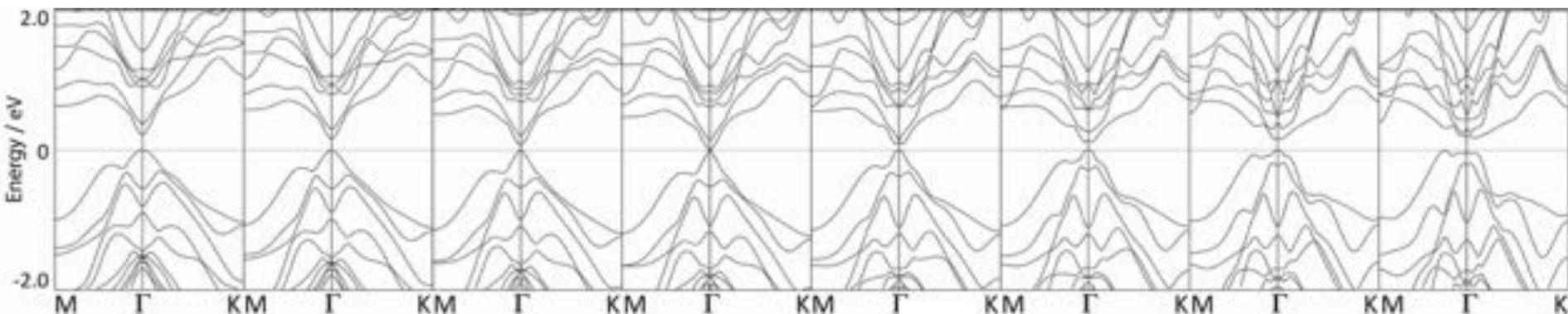
-0.38 GPa

-0.3 GPa

0 GPa

1 GPa

3 GPa

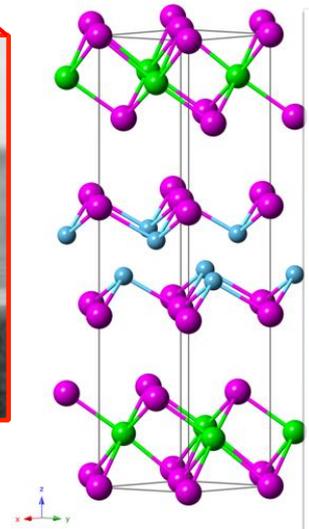
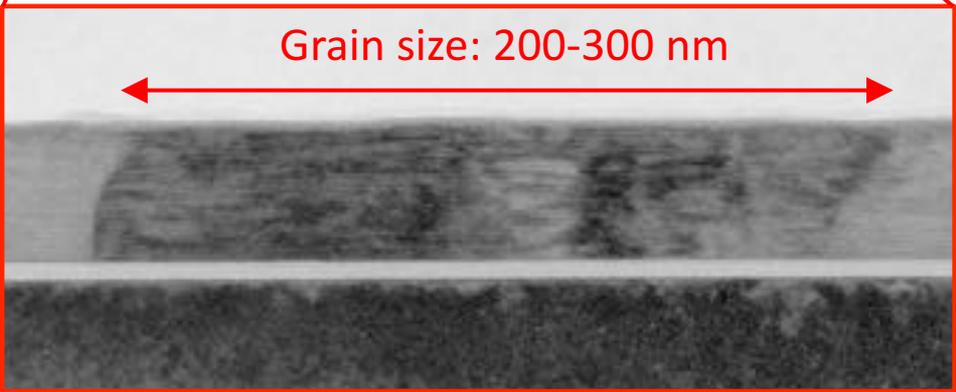


Y. Saito et al., *ACS Appl. Mater. Interfaces*, **9**, 23918 (2017)

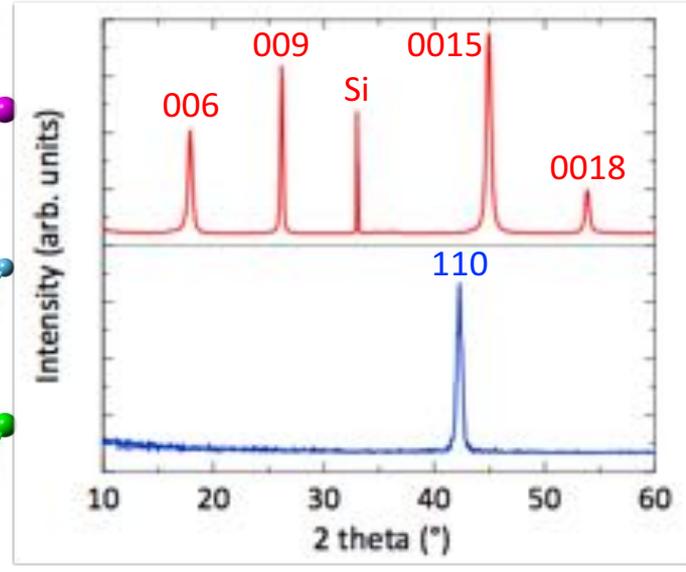
Fabrication of superlattice films

Sputter grown GeTe/Sb₂Te₃ superlattice film

Cross-sectional TEM image

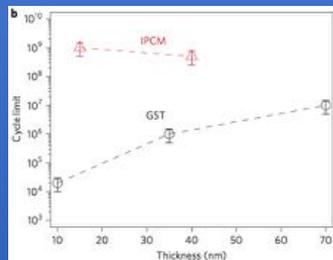
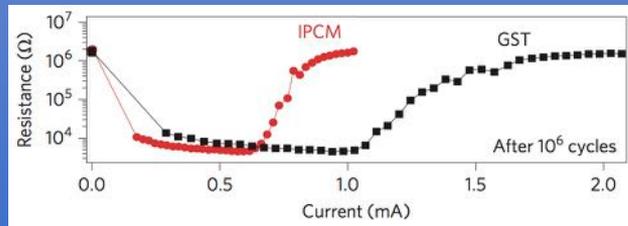
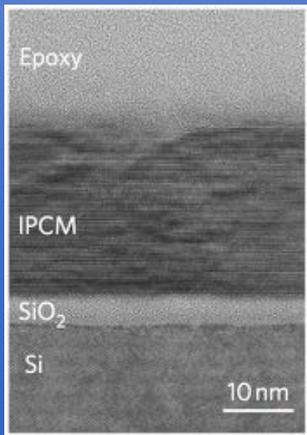


XRD (out-of-plane, in-plane)



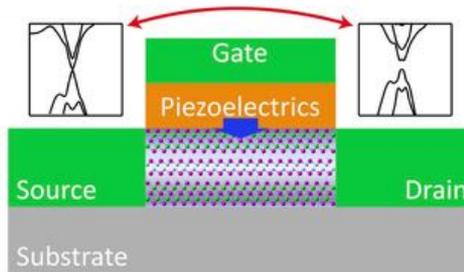
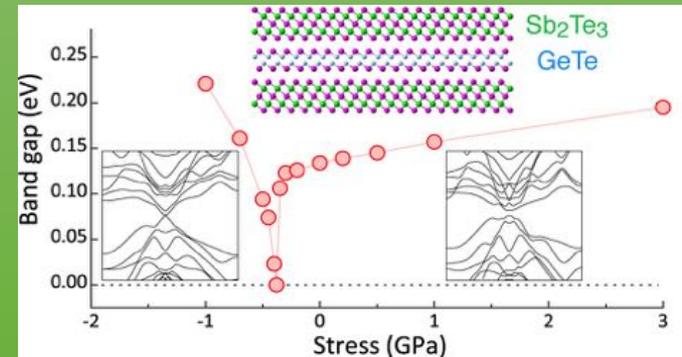
Applications

Phase change memory



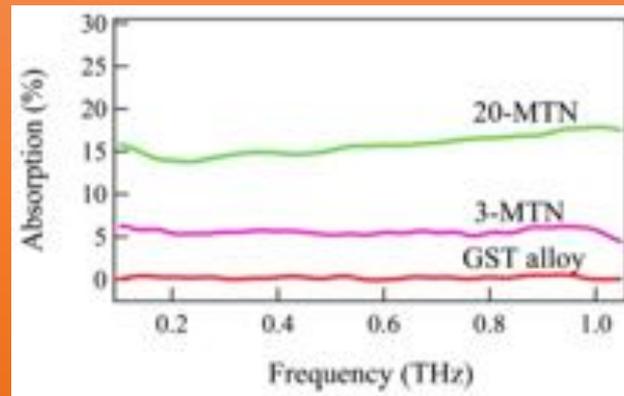
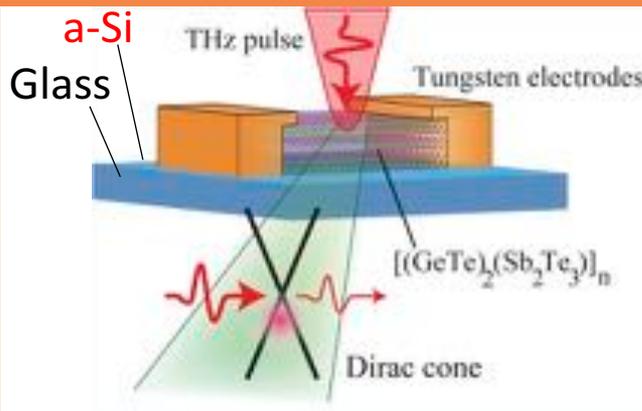
R. E. Simpson et al., *Nat. Nanotech.* **6**, 501 (2011)

Switching device

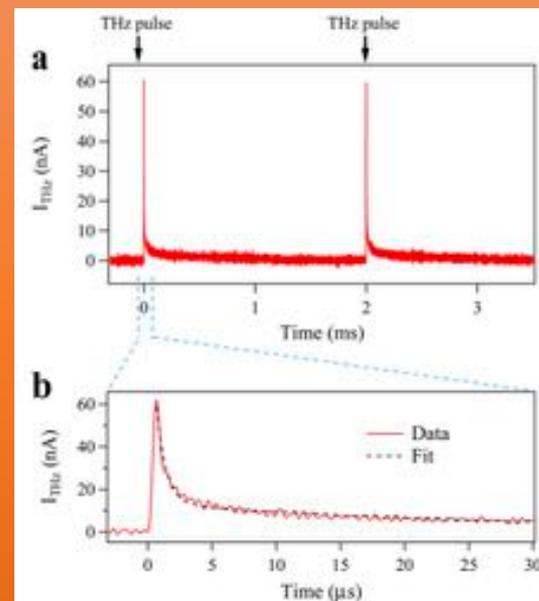


Y. Saito et al., *ACS Appl. Mater. Interfaces*, **9**, 23918 (2017)

THz detector



K. Makino et al., *ACS Appl. Mater. Interfaces*, **8**, 32408 (2016)



Summary

- $\text{MoTe}_2/\text{Sb}_2\text{Te}_3$ heterostructure possesses both features of transition metal dichalcogenide and topological insulator. However, a large difference of band alignment makes difficult to harness their properties.
- $\text{GeTe}/\text{Sb}_2\text{Te}_3$ heterostructure is promising not only for phase change memory but also for novel electronic devices that exploit topological insulator properties.

Thank you for your attention!

Acknowledgement

This work was supported by CREST, JST (No. JPMJCR14F1) and by JSPS KAKENHI Grant Nos. 26886015 and 16K04896, Japan.

